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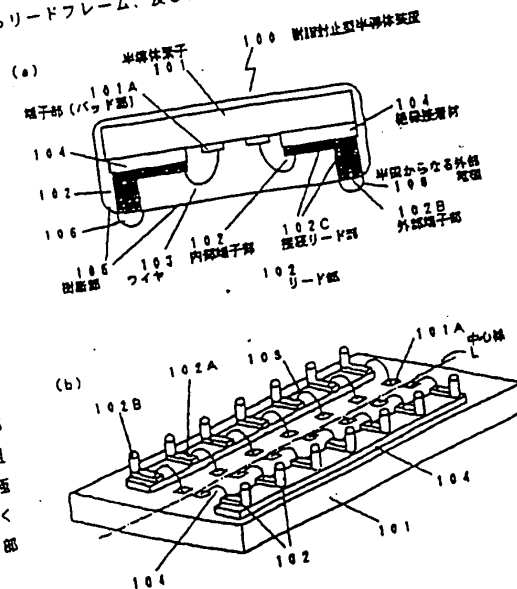
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(54) 【発明の名称】 樹脂封止型半導体装置とそれに用いられるリードフレーム、及び樹脂封止型半導体装置の製造方法

(57) 【要約】

【目的】 更なる樹脂封止型半導体装置の高集積化、高機能化が求められている中、半導体装置パッケージングにおけるチップの占有率を上げ、半導体装置の小型化に対応させ、同時に従来の T S O P 等の小型パッケージに困難であった更なる多ピン化を実現した樹脂封止型半導体装置を提供する。

【構成】 半導体素子の端子側の面に、半導体素子の端子と電気的に接続するための内部端子部と、半導体素子の端子側の面へ直交して外部へと向く外部回路への接続のための外部端子部と、前記内部端子部と外部端子部とを連絡する接続リード部とを一体とした複数のリード部とを、絶縁接着材層を介して、固着して設けており、且つ、回路基板等への実装のための半田からなる外部電極とを前記複数の各リードの外部端子部に連結させ、少なくとも前記半田からなる外部電極の一部は樹脂部より外部に露出させて設けている。



〔特許請求の範囲〕

〔請求項1〕 半導体素子の端子側の面に、半導体素子の端子と電気的に結線するための内部端子部と、半導体素子の端子側の面へ直交して外部へと向く外部回路への接続のための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体としたリード部を複数個、絶縁接着材層を介して、固着して設けており、且つ、回路基板等への実装のための半田からなる外部電極を前記複数の各リードの外部端子部に連結させ、少なくとも前記半田からなる外部電極の一部は樹脂部より外部に露出させて設けていることを特徴とする樹脂封止型半導体装置。

〔請求項2〕 請求項1において、半導体素子の端子は半導体素子の端子面の一方の辺の略中心部線上にそって配置されており、リード部は複数の端子を挟むように対向し前記一方の辺に沿って設けられていることを特徴とする樹脂封止型半導体装置。

〔請求項3〕 半導体素子の端子と電気的に結線するための内部端子部と、外部回路と接続するための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とし、該外部端子部を、接続リード部を介して、リードフレーム面から直交する一方向側に突出させ、対向し先端部同士で連結部を介して接続する一対の内部端子部を複数設けており、且つ、各外部端子部の外側で、接続リード部と連結し、一体として全体を保持する外枠部を設けていることを特徴とするリードフレーム。

〔請求項4〕 半導体素子の端子側の面に、半導体素子の端子と電気的に結線するための内部端子部と、半導体素子の端子側の面へ直交して外部へと向く外部回路への接続のための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とした複数のリード部とを、絶縁接着材層を介して、固着して設けており、且つ、回路基板等への実装のための半田からなる外部電極を前記複数の各リードの外部端子部に連結させ、少なくとも前記半田からなる外部電極の一部は樹脂部より外部に露出させて設けている樹脂封止型半導体装置の製造方法であって、少なくとも、(A) エッチング加工で、半導体素子の端子と電気的に結線するための内部端子部と、外部回路と接続するための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とし、該外部端子部を、接続リード部を介して、リードフレーム面から直交する一方向側に突出させ、対向し先端部同士で連結部を介して接続する一対の内部端子部を複数設けており、且つ、各外部端子部の外側で、接続リード部と連結し、一体として全体を保持する外枠部を設けているリードフレームを作製する工程、(B) リードフレームの外部端子部側でない面（裏面）に材料を設け、打ち抜き金型により、対向する内部端子部とを接続する連結部と該連結部に対応する位置に設

けられた絶縁材とを打ち抜き、リードフレームの打ち抜かれた部分が半導体素子の端子部にくるようにして、前記接着材を介して、リードフレーム全体を半導体素子へ搭載する工程、(C) リードフレームの外枠部を含む不要の部分を打ち抜き金型により切断除去する工程、

(D) 半導体素子の端子部と、切断されて、半導体素子へ搭載された内部端子部の先端部とをワイヤボンディングした後に、樹脂により外部端子部面のみを外部に露出させる全体を封止する工程、(E) 前記外部に露出した

外部端子部面に半田からなる外部電極を作製する工程、とを含むことを特徴とする樹脂封止型半導体装置の製造方法。

〔発明の詳細な説明〕

〔0001〕

〔産業上の利用分野〕 本発明は、半導体素子を搭載する樹脂封止型の半導体装置（プラスチックパッケージ）に関し、特に、実装密度を向上させ、且つ、多ピン化に対応できる半導体装置とその製造方法に関する。

〔0002〕

〔従来の技術〕 近年、半導体装置は、高集積化、小型化技術の進歩と電子機器の高性能化と軽薄短小化の傾向（時流）から、LSIのASICに代表されるように、ますます高集積化、高機能化になってきている。これに伴い、リードフレームを用いた封止型の半導体装置プラスチックパッケージにおいても、その開発のトレンドが、SOJ (Small Outline J-Lead Package) やQFP (Quad Flat Package) のような表面実装型のパッケージを経て、TSOP (Thin Small Outline Package) の開発による薄型化を主軸としたパッケージの小型化へ、さらにはパッケージ内部の3次元化によるチップ収納効率向上を目的としたLOC (Lead On Chip) の構造へと進展してきた。しかし、樹脂封止型半導体装置パッケージには、高集積化、高機能化とともに、更に一層の多ピン化、薄型化、小型化が求められており、上記従来のパッケージにおいてもチップ外周部分のリードの引き回しがあるため、パッケージの小型化に限界が見えてきた。また、TSOP等の小型パッケージにおいては、リードの引き回し、ピンピッチから多ピン化に対しても限界が見えてきた。

〔0003〕

〔発明が解決しようとする課題〕 上記のように、更なる樹脂封止型半導体装置の高集積化、高機能化が求められており、樹脂封止型半導体装置パッケージの一層の多ピン化、薄型化、小型化が求められている。本発明は、このような状況のもと、半導体装置パッケージサイズにおけるチップの占有率を上げ、半導体装置の小型化に対応させ、回路基板への実装面積を低減できる、即ち、回路基板への実装密度を向上させることができる樹脂封止型半導体装置を提供しようとするものである。また、同時

に従来の T S O P 等の小型パッケージに困難であった更なる多ピン化を実現しようとするものである。

〔 0 0 0 4 〕

〔課題を解決するための手段〕本発明の樹脂封止型半導体装置は、半導体素子の端子側の面に、半導体素子の端子と電気的に結線するための内部端子部と、半導体素子の端子側の面へ直交して外部へと向く外部回路への接続のための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とした複数のリード部とを、絶縁接着材層を介して、固着して設けており、且つ、回路基板等への実装のための半田からなる外部電極を前記複数の各リードの外部端子部に連結させ、少なくとも前記半田からなる外部電極の一部は樹脂部より外部に露出させて設けていることを特徴とするものである。尚、上記において、内部端子部と外部端子部とを一体とした複数のリード部の配列を半導体素子の端子側面上に二次元的に配列し、外部電極部を半田ボールにて形成することにより B G A (B a l l G r i d A r r a y) タイプの樹脂封止型半導体装置とすることもできる。

〔 0 0 0 5 〕そして、上記において、半導体素子の端子は半導体素子の端子面の一对の辺の略中心部線上にそって配置されており、リード部は複数の端子を挟むように対向し前記一对の辺に沿って設けられていることを特徴とするものである。また、本発明のリードフレームは、樹脂封止型半導体装置用のリードフレームであって、半導体素子の端子と電気的に結線するための内部端子部と、外部回路と接続するための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とし、該外部端子部を、接続リード部を介して、リードフレーム面から直交する一方向側に突出させ、対向し先端部同士で連結部を介して接続する一对の内部端子部を複数設けており、且つ、各外部端子部の外側で、接続リード部と連結し、一体として全体を保持する外枠部を設けていることを特徴とするものである。尚、上記リードフレームにおいて、内部端子部と外部端子部とそれとを連結する接続リード部とを一体とした組みを複数リードフレーム面に二次元的に配列するして形成することにより B G A (B a l l G r i d A r r a y) タイプの樹脂封止型半導体装置用のリードフレームとすることもできる。

〔 0 0 0 6 〕本発明の樹脂封止型半導体装置の製造方法は、半導体素子の端子側の面に、半導体素子の端子と電気的に結線するための内部端子部と、半導体素子の端子側の面へ直交して外部へと向く外部回路への接続のための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とした複数のリード部とを、絶縁接着材層を介して、固着して設けており、且つ、回路基板等への実装のための半田からなる外部電極を前記複数の各リードの外部端子部に連結させ、少なくとも前記半田からなる外部電極の一部は樹脂部より外部に露出させて設けていることを特徴とするものである。尚、上記において、内部端子部と外部端子部とを一体とした複数のリード部の配列を半導体素子の端子側面上に二次元的に配列し、外部電極部を半田ボールにて形成することにより B G A (B a l l G r i d A r r a y) タイプの樹脂封止型半導体装置とすることもできる。

記半田からなる外部電極の一部は樹脂部より外部に露出させて設けている樹脂封止型半導体装置の製造方法であって、少なくとも、(A) エッチング加工にて、半導体素子の端子と電気的に結線するための内部端子部と、外部回路と接続するための外部端子部と、前記内部端子部と外部端子部とを連結する接続リード部とを一体とし、該外部端子部を、接続リード部を介して、リードフレーム面から直交する一方向側に突出させ、対向し先端部同士で連結部を介して接続する一对の内部端子部を複数設けており、且つ、各外部端子部の外側で、接続リード部と連結し、一体として全体を保持する外枠部を設けているリードフレームを作製する工程、(B) 前記リードフレームの外部端子部側でない面(裏面)に絶縁材を設け、打ち抜き金型により、対向する内部端子部同士を接続する連結部と該連結部に対応する位置に設けられた絶縁材を打ち抜き、リードフレームの打ち抜かれた部分が半導体素子の端子部にくるようにして、前記接着材を介して、リードフレーム全体を半導体素子へ搭載する工程、(C) リードフレームの外枠部を含む不要の部分を打ち抜き金型により切断除去する工程、(D) 半導体素子の端子部と、切断されて、半導体素子へ搭載された内部端子部の先端部とをワイヤボンディングした後に、樹脂により外部端子部面のみを外部に露出させて全体を封止する工程、(E) 前記外部に露出した外部端子部面に半田からなる外部電極を作製する工程、とを含むことを特徴とするものである。

〔 0 0 0 7 〕

〔作用〕本発明の樹脂封止型半導体装置は、上記のような構成にすることにより、半導体装置パッケージサイズにおけるチップの占有率を上げ、半導体装置の小型化に対応できるものとしている。即ち、半導体装置の回路基板への実装面積を低減し、回路基板への実装密度の向上を可能としている。詳しくは、内部端子部、外部端子部とを一体とした複数のリード部を半導体素子面に絶縁接着材を介して固定し、前記外部端子部に半田からなる外部電極部を連結させていることにより、装置の小型化を達成している。そして、上記半田からなる外部電極部を、半導体素子面に略平行な面で二次元的に配列することにより、半導体装置の多ピン化を可能としている。半田からなる外部電極部を半田ボールとし、二次元的に該外部電極部を配列した場合には B G A タイプとなり、半導体装置の多ピン化にも対応できる。また、上記において、半導体素子の端子が半導体素子の端子面の一对の辺の略中心部線上にそって配置され、リード部は複数の端子を挟むように対向し前記一对の辺に沿って設けられており、簡単な構造とし、量産性に適した構造としている。本発明のリードフレームは、上記のような構成にすることにより、上記樹脂封止型半導体装置の製造を可能とするものであるが、通常のリードフレームと同様のエッチング加工の内、

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社製)を用いたが、他には、シリコン變成ポリイミド I
TA1715 (住友ベークライト株式会社)や熱硬化型
接着剤 HG5200 (巴川製紙株式会社株製)等が挙
げられる。上記実施例では、半田ペーストからなる外部
電極であるが、この部分は半田ボールに代えても良い。
尚、本実施例樹脂封止型半導体装置は、上記のように、
パッケージ面積が略半導体装置の面積に相当する。面積
的に小型化されたパッケージであるが、厚み方向につい
ても、略 1.0 mm 厚以下にすることができ、薄型も同
時に達成できるものである。本実施例においては外部電
極部を、半導体素子の端子部 (パッド部) に沿い 2 列に
配列したが、半導体素子の端子の位置を二次元的に配置
し、内部端子部と外部端子部との一体となった組みを複
数、半導体素子の端子面側に配列して搭載す
ることにより、半導体素子の、一層の多ピン化に十分対
応できる。

応てくる。

【0009】次いで、本発明のリードフレームを挙げ、図にもとづいて説明する。本実施例リードフレームは、上記実施例半導体装置に用いられたものである。図2は実施例リードフレームの平面図を示すもので、図2中、200はリードフレーム、201は内部端部、202は外部端子部、203は接続リード部、204は連結部、205は外枠部である。リードフレームは42合金（Ni42%のFe合金）からなり、リードフレームの厚さは、内部端子部のある薄肉部で0.05mm、外部端子部のある厚肉部で0.2mmである。内部端子部の対向する先端部同士を連結する連結部205も薄肉（0.05mm厚）に形成されており、後述する半導体装置を作製する際の打ち抜き金型にて打ち抜きし易い構造となっている。本実施例では外部端子部202は九状であるが、これに限定はされない。また、リードフレーム素材として42合金を用いたがこれに限定されない。銅系合金でも良い。

を塗布し、乾燥した。(図3(b))
次いで、リードフレーム素材300の両面から所定のパ
ターン版を用いてレジストの所定の部分のみに露光を行
った後、現像処理し、レジストパターン301Aを形成
した。(図3(c))
尚レジストとしては東京応化株式会社製のネガ型液状レ
ジスト(PMERレジスト)を使用した。次いで、レジ
ストパターン301Aを耐腐蝕性膜として、57°C、
48ホーメの塩化第二鉄水溶液にて、リードフレーム素
材300の両面からスブレイエッチングして、外形形状

の平面図が図2に示されるリードフレームを作製した(図3(d))。図2(b)のは、図2のA1-A2における断面図である。この後、レジストを剥離した後、洗浄処理を施した後、所定の箇所(内部端子部分を含む領域)のみに金メッキ処理を行った。(図3(e))尚、上記リードフレームの製造工程においては、図2(b)に示すように、厚肉部と薄肉部を形成するため、外部端子形成面側からのエッチング(腐蝕)を多く行い、反対面側からは少なめにエッチング(腐蝕)を行った。また、金メッキに代え、銀メッキやパラジウムメッキでも良い。上記のリードフレームの製造方法は、1ヶの半導体装置を作製するために必要なリードフレーム1ヶの製造方法であるが、通常は生産性の面から、リードフレーム素材をエッチング加工する際、図2に示すリードフレームを複数個面付けした状態で作製し、上記の工程を行う。この場合は、図2に示す外枠部205の一部に連結する枠部(図示していない)をリードフレームの外側に設けて面付け状態とする。

【0011】次に、上記のようにして作製されたリードフレームを用いた、本発明の樹脂封止型半導体装置の製造方法の実施例を図にそって説明する。図4は、本実施例樹脂封止型半導体装置の製造工程を示すものである。図3に示すようにして作製されたリードフレーム400の外部端子部402形成面(表面)と対向する裏面に、ポリイミド系熱硬化型の絶縁接着材(テープ)401(日立化成株式会社製、HM122C)を、400°C、6Kg/m²で1.0秒熱圧着して貼りつけた(図4(a))。この状態の平面図を図5に示す。この後打ち抜き金型405A、405Bにて(図4(b))、対向する内部端子部の先端部を連結する連結部403と、その部分の絶縁接着材(テープ)401とを打ち抜いた。(図4(c))

次いで、外枠打ち抜きおよび圧着用金型406A、406Bを用い、外枠部404を含む不要の部分を取り除く(図4(d))と同時に、絶縁接着材404を介して半導体素子407上にリード部408の熱圧着を行った。(図4(e))

尚、この図4(d)に示す、接続リードと連結してリードフレーム全体を支えている外枠部204を含む不要の部分を取り除くは、樹脂封止した後に行っても良い。この場合には、通常の単層リードフレームを用いたQFPパッケージ等のようにダムバー(図示していない)を設けると良い。リード部410を半導体素子411へ搭載した後、ワイヤー414により、半導体素子の端子(パッド)411Aとリード部410の内部端子410Aとを電気的に結線した。(図4(f))

その後、所定の金型を用い、エポキシ系の樹脂415でリード部410の外部端子部410Bのみを露出させて、全体を封止した。(図4(g))

ここでは、専用の金型(図示していない)を用いたが

所定の面(外部端子部)を残し樹脂封止できれば、必ずしも金型は必要としない。次いで、露出されている外部端子部410B上に半田ペーストをスクリーン印刷により塗布し、半田(ペースト)からなる外部電極416を作製し、本発明の樹脂封入型半導体装置を作製した。(図4(h))

尚、半田からなる外部電極416の作製は、スクリーン印刷に限定されるものではなく、リフローまたはポッティング等でも、回路基板と半導体装置との接続に必要な量の半田が得られれば良い。

【0012】

【発明の効果】本発明は、上記のように、更なる樹脂封止型半導体装置の高集積化、高機能化が求められる状況のもと、半導体装置パッケージサイズにおけるチップの占有率を上げ、半導体装置の小型化に対応させ、回路基板への実装面積を低減できる、即ち、回路基板への実装密度を向上させることができる半導体装置の提供を可能としたものであり、同時に従来のTSP等の小型パッケージに困難であった更なる多ピン化を実現した樹脂封止型半導体装置の提供を可能としたものである。

【図面の簡単な説明】

【図1】実施例の樹脂封入型半導体装置の概略断面図及び要部概略図

【図2】実施例のリードフレームの平面図

【図3】実施例のリードフレームの製造工程図

【図4】実施例の樹脂封止型半導体装置の製造工程図

【図5】実施例のリードフレームに絶縁接着材を貼りつけた状態の平面図

【符号の説明】

100	樹脂封止型半導体装置
101	半導体素子
101A	端子部(パッド部)
102	リード部
102A	内部端子部
102B	外部端子部
102C	接続リード部
103	ワイヤ
104	絶縁接着材
105	樹脂部
106	半田(ペースト)からなる外部電極
200	リードフレーム
201	内部端子部
202	外部端子部
203	接続リード部
204	連結部
205	外枠部
300	リードフレーム素材
301	レジスト

プロセッサ 13.43 ニホンアイソール(KK)ノノアセンサ

特開平8-125066

(6)

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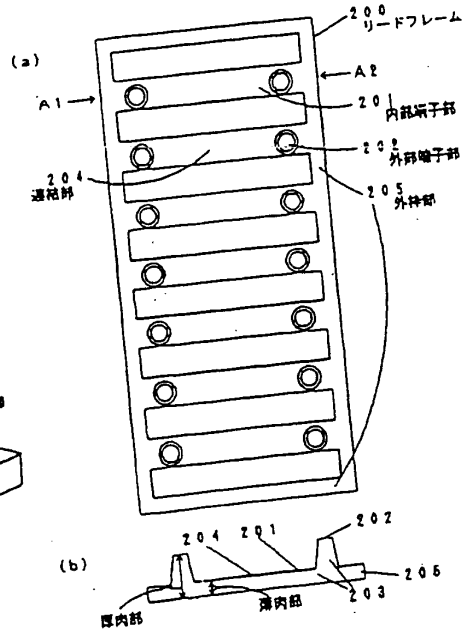
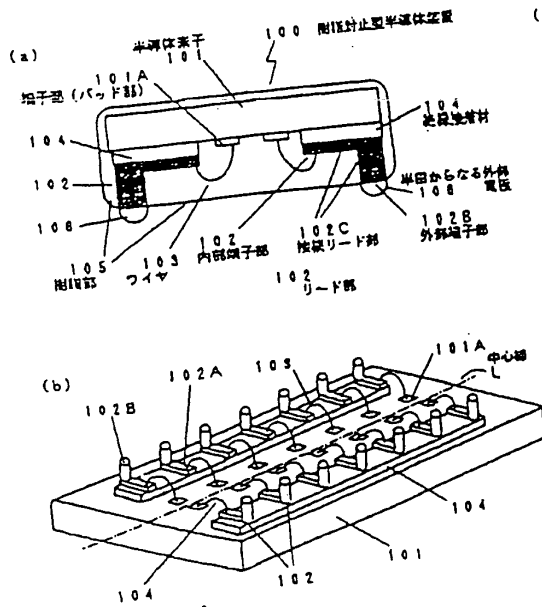
- 303A 内部端子部
- 303B 外部端子部
- 304 連結部
- 305 金メッキ部
- 306 外枠部
- 400 リードフレーム
- 401 絶縁接着材(テープ)
- 402 外部端子部
- 403 連結部

- 405A, 405B
- 406A, 406B
- 410
- 410A
- 410B
- 410C
- 411
- 411A
- 415

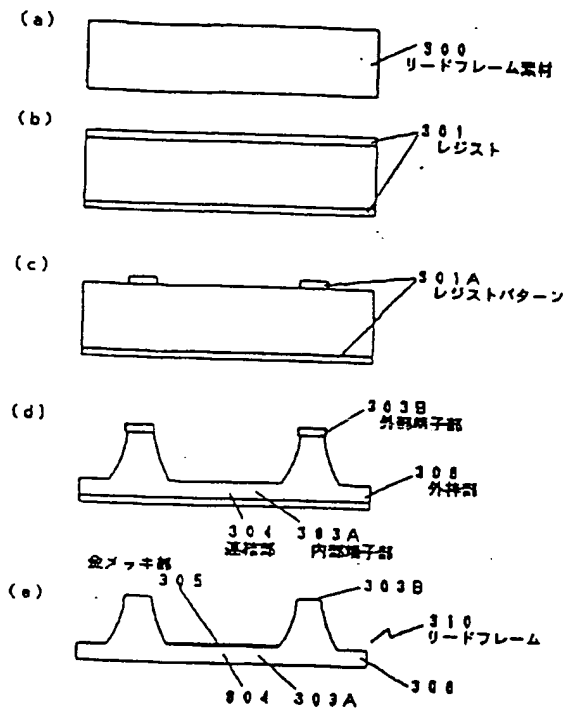
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- 外枠打ち抜きおよび圧着用金型
- リード部
- 内部端子部
- 外部端子部
- 接続リード部
- 半導体素子
- ワイヤー
- 樹脂

(図2)

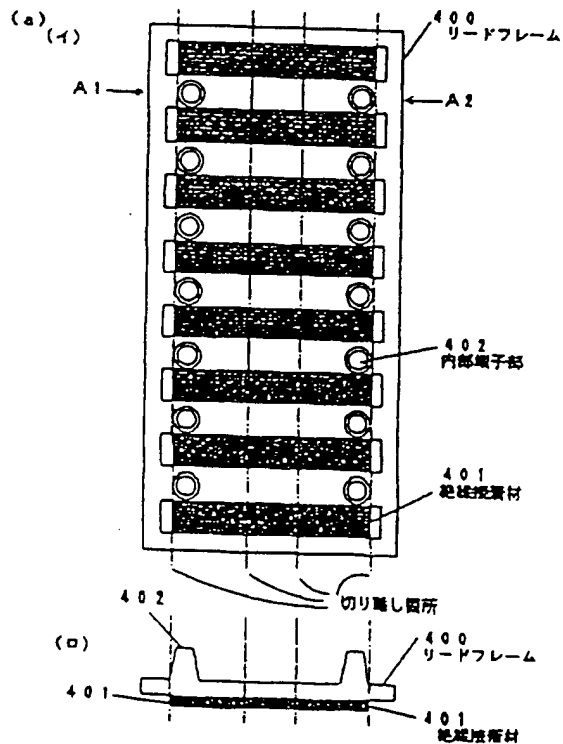
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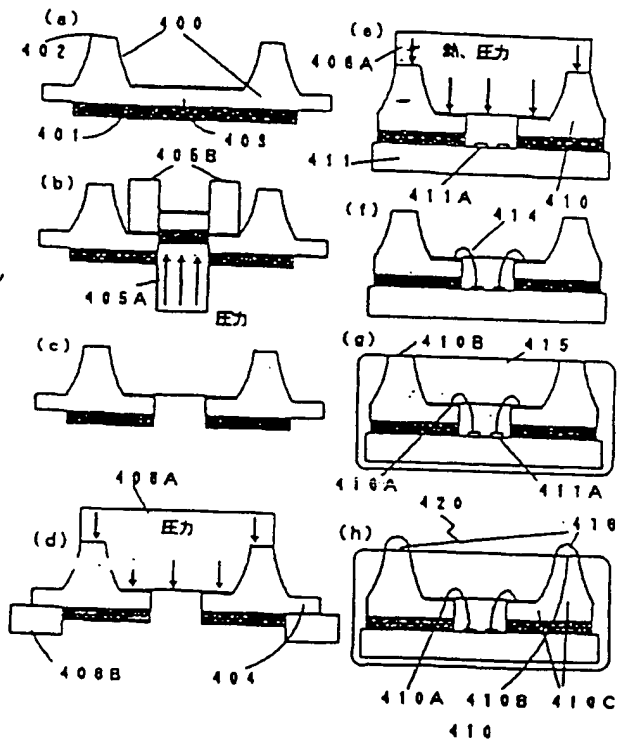
【 図 3 】



【 図 5 】



【 図 4 】



Japanese Patent Laid-Open Publication No. Heisei 8-125066

[TITLE OF THE INVENTION]

5 Resin Encapsulated Semiconductor Device, Lead Frame
Used Therein, and Fabrication Method for the Resin
Encapsulated Semiconductor Device

[CLAIMS]

- 10 1. A resin encapsulated semiconductor device
comprising:
a semiconductor chip;
a plurality of leads fixedly attached to a terminal-
end surface of the semiconductor chip by an insulating
adhesive interposed between the semiconductor chip and the
15 leads, each of the leads including integral portions, that
is, an inner terminal portion adapted to be electrically
connected to an associated one of terminals of the
semiconductor chip, an outer terminal portion extending
outwardly in a direction orthogonal to the terminal-end
20 surface of the semiconductor chip and adapted to be
connected to an external circuit, and a connecting lead
portion adapted to connect the inner and outer terminal
portions to each other; and
outer electrodes each connected to the outer terminal
25 portion of an associated one of the leads and made of

solder to allow the semiconductor device to be mounted on a circuit board, at least a part of the outer leads being externally exposed from a resin encapsulate.

5 2. The resin encapsulated semiconductor device according to claim 1, wherein the terminals of the semiconductor chip are arranged along a substantially center line between a pair of sides of the semiconductor chip on the terminal-end surface of the semiconductor chip, and the leads are arranged in two facing sets along the
10 sides of the semiconductor chip, respectively, in such a fashion that the terminals of the semiconductor chip are interposed between the two facing lead sets.

15 3. A lead frame comprising:
 a plurality of leads each including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of a semiconductor chip, an outer terminal portion adapted to be
20 be connected to an associated one of terminals of an external circuit, and a connecting lead portion adapted to connect the inner and outer terminal portions to each other;
 each of the outer terminal portions of the leads
25 being protruded in a direction orthogonal to a lead frame

surface via an associated one of the connecting lead portions;

the inner lead portions of the leads being arranged in pair in such a fashion that the leads of each lead pair
5 have facing tips, respectively;

connecting portions each adapted to connect the facing tips of the leads included in an associated one of the lead pairs; and

an outer frame portion arranged outside the outer
10 terminal portions and connected to the connecting lead portions in such a fashion that they form an integral structure together, thereby protecting the entire portion of the lead frame.

15 4. A method for fabricating a semiconductor device including a semiconductor chip, a plurality of leads fixedly attached to a terminal-end surface of the semiconductor chip by an insulating adhesive interposed between the semiconductor chip and the leads, each of the
20 leads including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of the semiconductor chip, an outer terminal portion extending outwardly in a direction orthogonal to the terminal-end surface of the semiconductor
25 chip and adapted to be connected to an external circuit,

and a connecting lead portion adapted to connect the inner and outer terminal portions to each other; and outer electrodes each connected to the outer terminal portion of an associated one of the leads and made of solder to allow
5 the semiconductor device to be mounted on a circuit board, at least a part of the outer leads being externally exposed from a resin encapsulate, comprising the steps of:

(A) fabricating a lead frame including a plurality of leads each including integral portions, that is, an inner
10 terminal portion adapted to be electrically connected to an associated one of terminals of a semiconductor chip, an outer terminal portion adapted to be connected to an associated one of terminals of an external circuit, and a connecting lead portion adapted to connect the inner and
15 outer terminal portions to each other, each of the outer terminal portions of the leads being protruded in a direction orthogonal to a lead frame surface via an associated one of the connecting lead portions, the inner lead portions of the leads being arranged in pair in such a
20 fashion that the leads of each lead pair have facing tips, respectively, connecting portions each adapted to connect the facing tips of the leads included in an associated one of the lead pairs, and an outer frame portion arranged outside the outer terminal portions and connected to the
25 connecting lead portions in such a fashion that they form

an integral structure together, thereby protecting the entire portion of the lead frame;

5 (B) applying an insulating layer to a surface of the lead frame opposite to the outer terminal portions, punching out the connecting portions adapted to connect facing ones of the inner lead portions to each other along with portions of the insulating layer respectively arranged at regions corresponding to the connecting portions by use of punching dies, aligning the punched portions of the lead frame with the terminals of the semiconductor chip, and mounting the entire portion of the lead frame on the semiconductor chip by the adhesive interposed therebetween;

10 (C) cutting off unnecessary portions of the lead frame including the outer frame portion by use of punching dies, thereby removing the cut-off portions;

15 (D) wire-bonding the terminals of the semiconductor chip with tips of the inner terminal portions mounted on the semiconductor chip, and encapsulating the semiconductor chip and the lead frame by a resin while allowing a surface of the lead frame toward the outer terminal portions to be externally exposed; and

20 (E) forming outer electrodes made of solder on the exposed lead frame surface toward the outer terminal portions.

[DETAILED DESCRIPTION OF THE INVENTION]

[FIELD OF THE INVENTION]

5 The present invention relates to a resin encapsulated semiconductor device (plastic package) in which a semiconductor chip is packaged, and more particularly to a semiconductor device configured to achieve an improvement in mounting density or to have a multi-pinned structure and a method for manufacturing such a semiconductor device.

10 [DESCRIPTION OF THE PRIOR ART]

15 Recently, semiconductor devices have been developed to have a higher integration degree and a higher performance by virtue of developments of techniques associated with an increase in integration degree and miniaturization and in pace with the tendency of electronic appliances to have a high performance and a light, thin, simple, and miniature structure. A representative example of such semiconductor devices is an ASIC of LSI. For instance, developments of resin encapsulated semiconductor device plastic packages have been advanced from surface-mounting packages such as SOJs (Small Outlined-Leaded Packages) or QFPs (Quad Flat Packages) to packages having a miniature structure mainly achieved in accordance with a thinness obtained by virtue of developments of TSOPs (Tin Small Outline Packages) or to LOC (Lead On Chip) structures

20

25

adapted to achieve an improvement in the chip packaging efficiency by virtue of developments of an internal three-dimensional package structure. In addition to an increase in integration degree and improvement in performance, there
5 has also been growing demand for an increase in the number of pins, thickness, and miniaturization of resin encapsulated semiconductor packages. In the above mentioned conventional packages, however, there is a limitation in miniaturization because those packages have a
10 structure in which leads are arranged around a chip. Similarly, leads are arranged around a chip in the case of miniature packages such as TSOPs. In such packages, there is also a limitation in increasing the number of pins due to the pin pitch used.

15

[SUBJECT MATTERS TO BE SOLVED BY THE INVENTION]

As mentioned above, there has been demand for an increase in integration degree and improvement in performance of resin encapsulated semiconductor devices.
20 Also, there has also been growing demand for an increase in the number of pins, thickness, and miniaturization of resin encapsulated semiconductor packages. In such situations, the present invention makes it possible to increase the occupancy degree of a chip in a semiconductor package with
25 a limited size while reducing the mounting area of the

semiconductor package on a circuit board to achieve a miniaturization of the resulting semiconductor device. That is, the present invention is adapted to provide a resin encapsulated semiconductor device capable of achieving an improvement in the mounting density thereof on a circuit board. Also, the present invention is adapted to achieve an increase in the number of pins which is difficult in miniature packages such as conventional TSOPs.

10 [MEANS FOR SOLVING THE SUBJECT MATTERS]

The resin encapsulated semiconductor device of the present invention is characterized in that it comprises: a semiconductor chip; a plurality of leads fixedly attached to a terminal-end surface of the semiconductor chip by an insulating adhesive interposed between the semiconductor chip and the leads, each of the leads including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of the semiconductor chip, an outer terminal portion extending outwardly in a direction orthogonal to the terminal-end surface of the semiconductor chip and adapted to be connected to an external circuit, and a connecting lead portion adapted to connect the inner and outer terminal portions to each other; and outer electrodes each connected to the outer terminal portion of an associated one of the

leads and made of solder to allow the semiconductor device to be mounted on a circuit board, at least a part of the outer leads being externally exposed from a resin encapsulate. The above semiconductor device can be embodied into a BGA (Ball Grid Array) type resin encapsulated semiconductor device by arranging a plurality of leads each having an inner terminal portion and an outer terminal portion integral with each other in a two-dimensional fashion on the terminal-end surface of the semiconductor chip and forming the outer electrodes in the form of solder balls.

The above semiconductor device is also characterized in that the terminals of the semiconductor chip are arranged along a substantially center line between a pair of sides of the semiconductor chip on the terminal-end surface of the semiconductor chip, and the leads are arranged in two facing sets along the sides of the semiconductor chip, respectively, in such a fashion that the terminals of the semiconductor chip are interposed between the two facing lead sets. The lead frame of the present invention is characterized in that it comprises: a plurality of leads each including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of a semiconductor chip, an outer terminal portion adapted to be

connected to an associated one of terminals of an external circuit, and a connecting lead portion adapted to connect the inner and outer terminal portions to each other; each of the outer terminal portions of the leads being protruded in a direction orthogonal to a lead frame surface via an associated one of the connecting lead portions; the inner lead portions of the leads being arranged in pair in such a fashion that the leads of each lead pair have facing tips, respectively; connecting portions each adapted to connect the facing tips of the leads included in an associated one of the lead pairs; and an outer frame portion arranged outside the outer terminal portions and connected to the connecting lead portions in such a fashion that they form an integral structure together, thereby protecting the entire portion of the lead frame. The above lead frame can be embodied into a lead frame for a BGA (Ball Grid Array) type resin encapsulated semiconductor device by arranging a plurality of leads each having an inner terminal portion and an outer terminal portion integral with each other in a two-dimensional fashion on the terminal-end surface of the semiconductor chip and forming the outer electrodes in the form of solder balls.

The present invention is also characterized by a method for fabricating a semiconductor device including a semiconductor chip, a plurality of leads fixedly attached

to a terminal-end surface of the semiconductor chip by an insulating adhesive interposed between the semiconductor chip and the leads, each of the leads including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of the semiconductor chip, an outer terminal portion extending outwardly in a direction orthogonal to the terminal-end surface of the semiconductor chip and adapted to be connected to an external circuit, and a connecting lead portion adapted to connect the inner and outer terminal portions to each other; and outer electrodes each connected to the outer terminal portion of an associated one of the leads and made of solder to allow the semiconductor device to be mounted on a circuit board, at least a part of the outer leads being externally exposed from a resin encapsulate, comprising the steps of: (A) fabricating a lead frame including a plurality of leads each including integral portions, that is, an inner terminal portion adapted to be electrically connected to an associated one of terminals of a semiconductor chip, an outer terminal portion adapted to be connected to an associated one of terminals of an external circuit, and a connecting lead portion adapted to connect the inner and outer terminal portions to each other, each of the outer terminal portions of the leads being protruded in a direction orthogonal to a

lead frame surface via an associated one of the connecting lead portions, the inner lead portions of the leads being arranged in pair in such a fashion that the leads of each lead pair have facing tips, respectively, connecting portions each adapted to connect the facing tips of the leads included in an associated one of the lead pairs, and an outer frame portion arranged outside the outer terminal portions and connected to the connecting lead portions in such a fashion that they form an integral structure together, thereby protecting the entire portion of the lead frame; (B) applying an insulating layer to a surface of the lead frame opposite to the outer terminal portions, punching out the connecting portions adapted to connect facing ones of the inner lead portions to each other along with portions of the insulating layer respectively arranged at regions corresponding to the connecting portions by use of punching dies, aligning the punched portions of the lead frame with the terminals of the semiconductor chip, and mounting the entire portion of the lead frame on the semiconductor chip by the adhesive interposed therebetween; (C) cutting off unnecessary portions of the lead frame including the outer frame portion by use of punching dies, thereby removing the cut-off portions; (D) wire-bonding the terminals of the semiconductor chip with tips of the inner terminal portions mounted on the semiconductor chip, and

encapsulating the semiconductor chip and the lead frame by
a resin while allowing a surface of the lead frame toward
the outer terminal portions to be externally exposed; and
(E) forming outer electrodes made of solder on the exposed
5 lead frame surface toward the outer terminal portions.

[FUNCTIONS]

With the above mentioned configuration, the resin
encapsulated semiconductor device of the present invention
10 can increase the occupancy degree of the chip while
achieving a miniaturization thereof. That is, the resin
encapsulated semiconductor device is capable of reducing
the mounting area thereof on a circuit board and achieving
an improvement in the mounting density thereof on the
15 circuit board. In particular, the present invention
achieves a miniaturization of the semiconductor device by
fixedly attaching a plurality of leads each including an
inner terminal portion and an outer terminal portion
integral with each other to a surface of a semiconductor
20 chip by an insulating adhesive layer interposed between the
semiconductor chip and the leads, and connecting outer
electrodes made of solder to the outer terminal portions,
respectively. Also, the present invention achieves an
increase in the number of pins in the semiconductor device
25 by arranging the outer electrodes made of solder in a two-

dimensional fashion on a plane parallel to the surface of the semiconductor chip. Where the outer electrodes made of solder are formed in the form of solder balls and arranged in a two-dimensional fashion, a BGA type semiconductor device capable of achieving an increase in the number of pins can be obtained. In the above semiconductor device, the terminals of the semiconductor chip are arranged along a substantially center line between a pair of sides of the semiconductor chip on the terminal-end surface of the semiconductor chip, and the leads are arranged in two facing sets along the sides of the semiconductor chip, respectively, in such a fashion that the terminals of the semiconductor chip are interposed between the two facing lead sets. Thus, the semiconductor device has a simple structure suitable in regard to productivity. The lead frame of the present invention makes it possible to fabricate the above mentioned resin encapsulated semiconductor device by virtue of there above mentioned configuration thereof. However, this lead frame can be fabricated using a half etching method during an etching process as used for conventional lead frames. The method for fabricating a resin encapsulated semiconductor device in accordance with the present invention involves the steps of applying an insulating layer to a surface of the lead frame opposite to the outer terminal portions, punching out

the connecting portions adapted to connect facing ones of the inner lead portions to each other along with portions of the insulating layer respectively arranged at regions corresponding to the connecting portions by use of punching dies, aligning the punched portions of the lead frame with the terminals of the semiconductor chip, and mounting the entire portion of the lead frame on the semiconductor chip by the adhesive interposed therebetween, and cutting off unnecessary portions of the lead frame including the outer frame portion by use of punching dies, thereby removing the cut-off portions. Thus, a plurality of leads each including an inner terminal portion and an outer terminal portion integral with each other are mounted on a semiconductor chip. Accordingly, the present invention makes it possible to achieve a miniaturization of semiconductor devices. In accordance with the present invention, it is also possible to fabricate a resin encapsulated semiconductor device having an increased number of pins.

20

[EMBODIMENTS]

Hereinafter, embodiments of the present invention associated with resin encapsulated semiconductor devices will be described in conjunction with the annexed drawings. Fig. 1A is a cross-sectional view schematically

25

illustrating a resin encapsulated semiconductor device according to an embodiment of the present invention. Fig. 1B is a perspective view illustrating an essential part of the resin encapsulated semiconductor device. Figs. 1A and 5 1B, the reference numeral 100 denotes the resin encapsulated semiconductor device, 101 a semiconductor chip, 102 leads, 102A inner terminal portions, 102B outer terminal portions, 102C connecting lead portions, 101A contacts (pads), 103 wires, 104 an insulating adhesive, 105 a resin encapsulate, 106 outer electrodes made of solder (paste), respectively. The resin encapsulated semiconductor device according to this embodiment is fabricated using a lead frame which will be described hereinafter. In this resin encapsulated semiconductor 10 device, a plurality of L-shaped leads 102, each of which has an inner terminal portion 102A and an outer terminal portion 102 integral with each other, are mounted on a semiconductor chip 101 by means of an insulating adhesive 104. An outer electrode 106, which is made of solder, is 15 attached to each outer terminal portion 102B. The outer electrode 106 is outwardly protruded from a resin encapsulate 105. The resin encapsulated semiconductor device configured as mentioned above has a package area substantially equal to the entire area thereof. When this 20 semiconductor device is mounted on a circuit board, the 25

solder is melted and then solidified to allow the outer terminal portions 102B to be electrically connected to an external circuit. In the resin encapsulated semiconductor device according to the illustrated embodiment, contacts (pads) 101A provided at the semiconductor chip 101 are arranged in pairs along a center line L of the semiconductor chip 101 at opposite sides of the center line L in such a fashion that contacts included in each contact pair face each other. The outer terminal portion 102B of each lead is spaced apart from the inner terminal portion 102A of the lead. Between the inner and outer terminal portions 102A and 102B, a connecting lead portion 102C is interposed. The connecting lead portion 102C of each lead is bent in a direction orthogonal to the major surface of the semiconductor chip at a position near an associated one of the side surfaces of the semiconductor chip 101, so that it has an L shape. In each lead, the outer terminal portion 102B is arranged at an end of the connecting lead portion 102C. The outer terminal portions 102B of the leads are arranged in a one-dimensional fashion on a plane parallel to the major surface of the semiconductor chip 101. That is, the outer terminal portions 102B are arranged in two lines at opposite sides of the center line L. As mentioned above, one outer electrode 106 made of solder is connected to the outer terminal portion 102B of

each lead and outwardly exposed from the resin encapsulate 105.

For the insulating adhesive 104, a polyimide-based thermoplastic adhesive having a thickness of 100 μm (HM122C manufactured by Hitachi Chemical Co., Ltd.) is preferably 5 used. Alternatively, a silicon denaturalized polyimide adhesive (ITA1715 manufactured by Sumitomo Bakelite Co., Ltd.) or a thermosetting adhesive (HG5200 manufactured by Tomoekawa Papermaking Co., Ltd.) may be used. Although 10 outer electrodes made of solder paste are used in the illustrated embodiment, solder balls may be used.

As mentioned above, the resin encapsulated semiconductor device according to the illustrated embodiment has a package area substantially equal to the 15 entire area thereof. That is, the illustrated embodiment of the present invention provides a package having a compact structure in regard to area. In accordance with the present invention, a thinned package structure can also be provided in that it is also possible to reduce the 20 package thickness to about 1.0 mm or less. Although the outer electrodes have been described as being arranged in two lines along the contacts (pads) of the semiconductor chip, they may be arranged in a two-dimensional fashion. This is achieved by arranging contacts of the semiconductor 25 chip in a two-dimensional fashion. On the surface of the

semiconductor chip arranged with those contacts, a plurality of terminal sets each having an inner terminal and outer terminal integral with each other are arranged in a two-dimensional fashion. In this case, it is possible to
5 fabricate a semiconductor device using a semiconductor chip with an increased number of pins.

An embodiment of the present invention associated with a lead frame will now be described. The lead frame according to this embodiment is adapted to be used in the
10 above mentioned semiconductor device. Fig. 2 is a plan view of the lead frame according to this embodiment. In Fig. 2, the reference numeral 200 denotes a lead frame, 201 inner terminal portions, 202 outer terminal portions, 203 connecting lead portions, 204 a connecting portion, and 205
15 an outer frame portion, respectively. The lead frame is made of 42 ALLOY (namely, an Fe alloy containing 42% Ni). The lead frame has a thickness of 0.05 mm at its thinner portion, that is, the inner terminal portions, and a thickness of 0.2 mm at its thicker portion, that is, the
20 outer terminal portions. The connecting portion, which connects facing tips of the inner terminal portions to each other, has a thickness of 0.05 mm corresponding to that of the thinner portion. This connecting portion has a structure capable of allowing an easy punching thereof in
25 the fabrication of the semiconductor device, as described

hereinafter. Although the outer terminal portions 202 have a ball shape in the illustrated embodiment, they are not limited to this shape. Also, although the lead frame has been described as being made of the 42 ALLOY, it is not limited to this material. For the lead frame, a copper-based alloy may be used.

Now, fabrication of the lead frame according to the illustrated embodiment will be described in brief. Fig. 4 illustrates a process for fabricating the lead frame according to the illustrated embodiment. First, a lead frame blank 300 having a thickness of 0.2 mm was prepared which is made of a 42 ALLOY (an Fe alloy containing 42% Ni). The prepared lead frame blank 300 was then subjected to a cleaning process, thereby removing grease from the surfaces thereof (Fig. 3a). Subsequently, photoresist films 301 were coated over both surfaces of the lead frame blank 300, respectively. The coated photoresist films 301 were then dried (Fig. 3b).

Using desired pattern plates, the photoresist films 301 on both surfaces of the lead frame blank 300 were exposed to light at their desired portions. A developing process was then conducted to the light-exposed photoresist films 301, thereby forming photoresist patterns 301A.

For the photoreist films, a negative liquid-phase resist (PMER resist) manufactured by Tokyo Ohka Co., Ltd.

was used. Using the resist patterns 301A as anti-etch films, the lead frame blank 300 was subjected to a spray etching process at both surfaces thereof. The spray etching process was conducted using a ferric chloride solution of 48 BAUME at 57 °C. Thus, a lead frame having a structure of Fig. 2a was obtained (Fig. 3d). Fig. 2a is a plan view of the lead frame. Fig. 2b is a cross-sectional view taken along the line A1 - A2 of Fig. 2a. Thereafter, the remaining photoresist thin films were peeled off. The resulting structure was then subjected to a cleaning process. A gold plating process was subsequently conducted for desired portions of the lead frame, that is, regions including inner terminal portions (Fig. 3e).

In the fabrication process of the lead frame, the etching process was conducted with a large etch depth at one major surface of the lead frame blank where outer terminal portions are to be formed, and with a small etch depth at the other major surface of the lead frame. In place of the gold plating, silver or palladium plating may be utilized. The above mentioned lead frame fabrication process is adapted to manufacture a single lead frame required for the manufacture of a single semiconductor device. In terms of productivity, however, the etching process is conducted for lead frame units each corresponding to the single lead frame shown in Fig. 2. To

this end, a frame member (not shown) is provided at a desired portion of the peripheral edge of the lead frame so as to connect a desired part of the outer frame portion 205 shown in Fig. 2 to a corresponding one of an adjacent lead frame.

Using the lead frame fabricated as mentioned above, the resin encapsulated semiconductor device according to the present invention was fabricated. Now, a method for fabricating the resin encapsulated semiconductor device in accordance with an embodiment of the present invention will be described. Fig. 4 illustrates the method for fabricating the resin encapsulated semiconductor device in accordance with the embodiment of the present invention. A polyimide-based thermosetting insulating adhesive (tape) 401 (HM122C manufactured by Hitachi Chemical Co., Ltd.) was applied to one surface, formed with the outer terminal portions 402, of the lead frame 400 fabricated as in Fig. 3 and the outer surface of the lead frame 400 using a hot pressing process conducted at 400 °C and 6 Kg/m² for 1.0 second (Fig. 4a). The resulting structure is shown in Fig. 5 which is a plan view. Thereafter, the connecting portions 403 connecting facing tips of the inner terminal portions were punched using punching dies 405A and 405B (Fig. 4b). Also, portions of the insulating adhesive

(tape) corresponding to those connecting portions 403 were punched (Fig. 4c)

Subsequently, unnecessary portions of the lead frame including the outer frame 404 were cut off using outer frame punching and pressing dies 406A and 406B (Fig. 4d).
5 The lead frame was then bonded to a semiconductor chip 407 at its leads 410 under pressure while applying heat (Fig. 4e).

The process for cutting off the unnecessary portion
10 of the lead frame including the outer frame 404 supporting the entire portion of the lead frame along with the connecting lead portion, as shown in Fig. 4d, may be carried out after an resin encapsulating process. In this case, dam bars (not shown) are preferably provided, as in
15 QFP packages typically using a lead frame having a single layer structure. After the mounting of the leads 410 on the semiconductor chip 411, the inner terminal portion 410 of each lead 410 was electrically connected to an associated one of terminals (pads) 411A of the
20 semiconductor chip 411 (Fig. 4f).

Subsequently, an epoxy-based resin 415 was molded to encapsulate the resulting structure while exposing the outer terminal portions 410B of the leads 410 using a desired mold (Fig. 4g).

Although a specific mold, (not shown) was used for the above process in the illustrated case, use of such a die may be unnecessary in so far as the resin encapsulating process can be conducted under the condition in which
5 desired portions (outer terminal portions) of the lead frame are left. Thereafter, a solder paste was coated on the exposed outer terminal portions 410B in accordance with a screen printing process, thereby forming outer electrodes 416 made of solder (paste). Thus, the fabrication of the
10 resin encapsulated semiconductor device according to the present invention was achieved (Fig. 4h).

Although the formation of the outer electrodes 416 made of solder has been described as being achieved using a screen printing process, it may be achieved using a reflow
15 or bonding process in so far as an amount of solder required for a connection of the semiconductor device to a circuit board is obtained.

[EFFECTS OF THE INVENTION]

20 As apparent from the above description, the present invention makes it possible to increase the occupancy degree of a semiconductor chip in a semiconductor package in situations requiring new resin encapsulated semiconductor devices having a highly integrated structure
25 while exhibiting a high performance. The present invention

also makes it possible to reduce the area of the semiconductor device on a circuit board in order to cope with a compactness of the semiconductor device. That is, the present invention can provide a semiconductor device
5 capable of achieving an improvement in the mounting density on a circuit board. At the same time, the present invention can provide a resin encapsulated semiconductor device having a new multipinned structure which could not be realized in compact packages such as conventional TSOPs.